

Drexel University Temperature Sensors

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1. Introduction

This document summarizes background information and presents results related to temperature measurements in the Advanced Test Reactor (ATR) National Scientific User Facility (NSUF) Drexel University Project 31091 irradiation. As documented in Reference 1, the objective of this test was to assess the radiation performance of new ceramic materials for advanced reactor applications. Accordingly, irradiations of transition metal carbides and nitrides were performed using the Hydraulic Shuttle Irradiation System (HSIS) in the B-7 position and in static capsules inserted into the A-3 and East Flux Trap Position 5 locations of the ATR.

Only the HSIS capsules contained temperature sensors, consisting of quartz-encapsulated melt wire assemblies and Silicon Carbide (SiC) temperature monitors. A total of six HSIS titanium capsules were included in the test, and the capsules were irradiated for approximately 10 Effective Full Power Days (EFPDs) to a maximum fluence of 7×10^{19} n/cm² ($E > 1$ MeV). Pre-test thermal and physics analyses^{2,3} indicate that two capsules would be irradiated at 110 °C (with the SiC monitors receiving a 0.1 dpa dose); two capsules would be irradiated at 725 °C (with the SiC monitors receiving a 0.1 dpa dose); and two capsules would be irradiated at 1100 °C (with the SiC monitors receiving a 0.1 dpa dose). Figure 1 shows the design of the HSIS capsule with the location of a melt wire assembly (containing four melt wires) and the location of an SiC monitor. Figure 2 shows a radiograph of one of the capsules prior to irradiation.

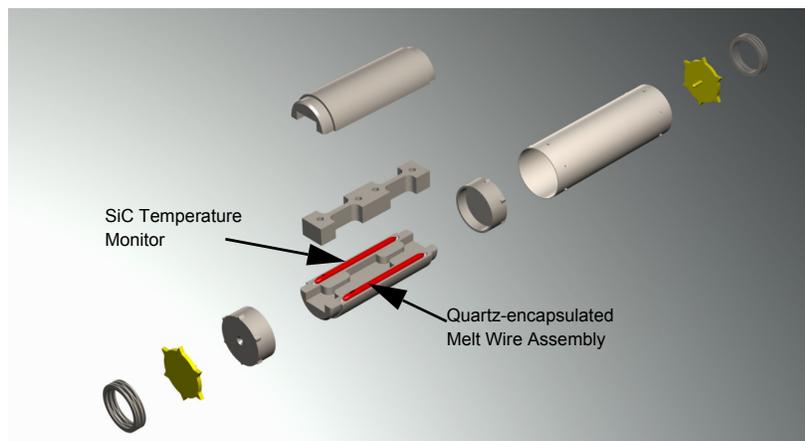


Figure 1. Drexel University HSIS capsule design.

This report documents results from an evaluation of the temperature sensors for two of the six HSIS capsules. One of the evaluated capsules (with a predicted irradiation temperature of 110 °C) will be identified as KGT-1368, while the other evaluated capsule (with a predicted irradiation temperature of 725 °C) will be identified as KGT-1370. (Capsules with predicted irradiation temperatures of 1100 °C were not evaluated because SiC has not been shown to be a reliable monitor if irradiated above the recrystallization temperature, e.g., above 800 °C.) It is critical to note that the KGT-1368 predicted irradiation temperature and dose and the KGT-1370 dose are below the recommended range for SiC temperature monitor use (see Section 3). Consequently, uncertainties in this evaluation cannot be readily quantified.



Figure 2. Radiograph of typical Drexel University capsule prior to irradiation.

2. Melt Wire Temperature Sensors

An evaluation of the melt wire assemblies was undertaken to validate temperature predictions from the pretest thermal and reactor physics analyses. Insights from melt wire evaluations can be used to select appropriate temperatures for more efficient SiC temperature monitor evaluations.

2.1. Selection and Prior Experience with Selected Wires

The melt wires listed in Table 1 were selected to bound estimated temperatures for the Drexel test. These materials were selected from a library of melt wire materials maintained by Idaho National Laboratory's (INL's) High Temperature Test Laboratory (HTTL). Many of the wires included in this test had their melting temperature evaluated using an HTTL differential scanning calorimeter (DSC).^{4,5} In addition, HTTL furnace tests of quartz encapsulated tubes containing materials from the HTTL melt wire library provide insights related to the ability to visually discern melting after heating to temperatures above melting.^{6,7} These insights are summarized in column 3 of Table 1.

Table 1. Summary of melt wires included in Drexel University test.

Melt Wire Material ^a	Melt Temperature (°C)	Comment
110 °C Capsules		
56.2 Bi 33.8 Pb 10 Sn	85.0	HTTL Evaluated (TEV-1175); furnace tests indicate morphology changes by 105 °C.
65 Bi 35 In	110.6	HTTL Evaluated (TEV-1175); furnace tests indicate discoloration and morphology changes by 117 °C.
55.2 Bi 44.8 Pb	126.4	HTTL Evaluated (TEV-1175); furnace tests indicate discoloration and morphology changes by 130 °C.
57 Bi 43 Sn	139.4	HTTL Evaluated (TEV-1175); furnace tests indicate discoloration and morphology changes by 145 °C.
725 °C Capsules		
Zn	419.3	HTTL evaluated (TEV-1141); Furnace tests difficult to interpret (some discoloration occurs in some tests after 335 °C; slight surface changes at 430 °C may indicate melt).

Table 1. Summary of melt wires included in Drexel University test. (continued)

Melt Wire Material ^a	Melt Temperature (°C)	Comment
80 Sb 20 Zn	507.8	HTTL evaluated (TEV-1175); Chards; Furnace tests indicate melting not until 520 to 540 °C; oxidation may have caused discrepancy.
Al	660.5	Furnace test results varied; Some results indicate discoloration and morphology observed by 670 °C and melting by 710 °C.
49 Ag 16 Cu 23 Zn 7.5 Mn 4.5 Ni	681.3	HTTL Evaluated (TEV-1175).
1100 °C Capsule - Side A		
1.8 Be 98.2 Cu	865.1	HTTL Evaluated (TEV-1175); furnace tests indicate discoloration 850 °C and morphology changes by 890 °C.
Ag	962.0	Phase diagram; Furnace tests indicate melting above 985 °C.
65 Cu 35 Au	995.6	HTTL Evaluated (TEV-1175); DSC results indicate melting easy to observe, but only morphology changes in furnace test above 1030 °C.
Cu	1083	Phase diagram. Only morphology changes in furnace tests above 1100 °C.
1100 °C Capsule - Side B		
1.8 Be 98.2 Cu	865.1	HTTL Evaluated (TEV-1175); furnace tests indicate discoloration 850 °C and morphology changes by 890 °C.
70 Cu 30 Ni	1191.0	HTTL Evaluated (TEV-1175); furnace tests indicate discoloration and morphology changes by 985 °C.
Ag	962.0	Phase diagram. Furnace tests indicate melting above 985 °C.
Au	1064	Phase diagram. Furnace tests indicate melting above 1075 °C.

a. Listed with weight percent of each element.

2.2. Initial Melt Wire Results

Post irradiation evaluations indicate that none of the quartz tubes experienced any darkening. The state of the wires was easily observed, but not easily photographed. Preliminary results are summarized in this section with recommendations for SiC temperature monitor evaluations.

2.2.1. 110 °C Results

Post-irradiation photos of KGT-1368 are too far out of focus to determine if any of the wire samples melted as indicated in Figure 3.



Figure 3. KGT-1368 (higher melting point material, 57 Bi 43 Sn, near painted end).

2.2.2. 725 °C Results

The quartz tube broke during disassembly. These photos are unclear, and it is unknown which melt wire materials remain in the tube fragment shown in Figure 4.

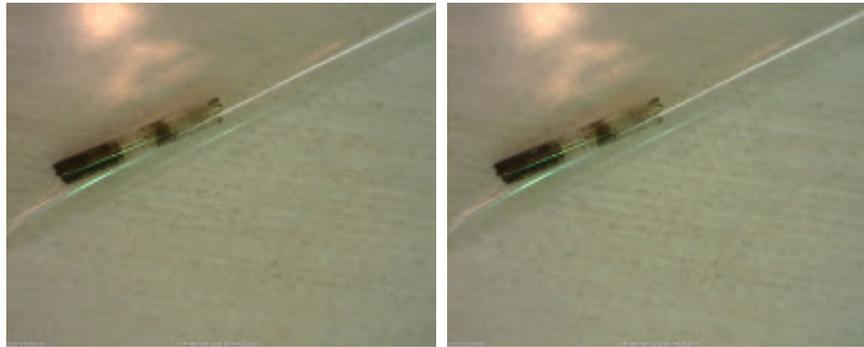


Figure 4. KGT-1370 (higher melting point material, 49 Ag 16 Cu 23 Zn 7.5 Mn 4.5 Ni, near painted end, but painted end not evident in fragment).

2.2.3. Conclusions and Recommendations for SiC Evaluations

Results presented in this section indicate that melt wire evaluation results are inconclusive. Table 2 summarizes recommendations for SiC monitor evaluations based on pre-test thermal analysis results.

Table 2. Preliminary melt wire evaluation for the Drexel University test.

Capsule	Comment and Recommendation
110 °C Capsule ^a	
KGT-1368	Photos too far out of focus for any conclusions.
	Recommendation for SiC Monitor Evaluations: Start SiC monitor evaluation at 40 °C, increment to the anneal temperatures of 50, 60, 80 and 100 °C, then increase the anneal temperature for subsequent data points by 10 °C until a change in resistivity is observed.
725 °C Capsules ^b	
KGT-1370	Photos too far out of focus for any conclusions.
	Recommendation for SiC Monitor Evaluations: Start SiC monitor evaluations at 40 °C, increment to the anneal temperature of 50 °C, increase the anneal temperature for subsequent data points by 50 °C and take measurements up to 650 °C, then increase the anneal temperature for subsequent data points by 10 °C increments until a change in resistivity is observed.

a. Estimated irradiation temperature and dose are lower than recommended ranges for SiC monitor use (see Section 3).

b. Estimated dose is lower than the recommended range for SiC monitor use (see Section 3).

3. SiC Temperature Monitors

As discussed in Section 1, SiC temperature monitors were incorporated into Drexel test capsules at the locations illustrated in Figures 1 and 2. (Note that these monitors were a fully dense chemical vapor deposition of silicon carbide procured from Dow Chemical Company.^a) Results from thermal analyses of the SiC monitors inserted in capsules designated KGT-1368 and KGT-1370 are reported in Table 3.

a. Purchased under Idaho National Laboratory quality assurance identifier QA165156.

Table 3. Estimated temperatures for SiC monitors.

Monitor Identification	Thermal Analysis Predictions (°C)
KGT-1368	110
KGT-1370	725

3.1. Background

SiC has been used as a post-irradiation monitor to infer peak irradiation temperature since the early 1960s. As noted in Reference 8, several researchers have observed that neutron irradiation induced lattice expansion of SiC anneals out when the post-irradiation annealing temperature exceeds the irradiation temperature. More recent evaluations⁸⁻¹⁰ infer peak irradiation temperatures using changes in electrical resistivity because of improved accuracy, ease of measurement, and reduced costs of the experimental setup. Comparisons of temperatures inferred from SiC measurements and thermocouple data indicate that accuracies of approximately 20 °C are possible for dose ranges of 1 to 8 dpa and temperatures from 200 to at least 800 °C.

There are several limitations associated with the use of SiC temperature monitors. The use of SiC as a temperature monitor is intended for constant temperature irradiations. Reference 9 cites several specific examples where temperature variations during irradiation can introduce uncertainty in the SiC monitor measurements including:

- *Irradiation temperatures rising during the latter part of irradiation.* SiC swelling saturates at low fluence. For damages greater than 0.1 dpa, the increasing temperature will anneal out defects that occur at the lower irradiation temperature, while creating stable defects at the higher temperature. When isochronal annealing is performed, lower temperature defects are removed; and the recovery curve will be smeared to somewhat higher temperatures. If the temperature increase during irradiation is not great, or the time at higher temperature not too long, then the original departure from linearity will still give the earlier irradiation temperature.
- *Irradiation temperatures decreasing during irradiation.* This decrease will lead to defects being created and frozen-in at the higher-temperature, while continuing to create lower temperature defects. The isochronal anneal will then give an indication of the lowest irradiation temperature (in this case at the end of the irradiation period), and the recovery curve will be smeared because it will continue to anneal higher and higher temperature stable defects.
- *Upward or downward temperature spikes during irradiation.* Depending on the time at temperature, the effect will be to smear the recovery curve.

However, if irradiation tests are conducted at or near a constant temperature when the reactor is at power, none of these situations are of concern.

In addition, there are other sources of uncertainty that one should consider when comparing results from SiC temperature monitors and analysis predictions for peak temperatures. For example, Reference 8 provides information regarding the influence manufacturing tolerances of gas gaps can have on temperature control in irradiation tests. Thermal analysis of prior tests have been shown to have errors of up to 100 °C in tests conducted at 1400 °C.

3.2. Experimental Setup

Electrical resistivity measurements were used to infer the peak irradiation temperature of the Drexel SiC monitors. Figure 5 depicts the equipment at the HTTL used to evaluate SiC monitors. The SiC monitors were heated isochronally in the annealing furnace. Based on the experiment analysis, the annealing temperatures were selected as specified in Section 2.2.3. The annealing furnace is located under a ventilation hood within a stainless steel enclosure. Annealing temperatures are recorded using a National Institute Standards and Technology (NIST) traceable, calibrated thermocouple inserted into an alumina tube in the furnace. After each isochronal annealing, the specimens are placed in a specialized fixture designed to take resistance measurements and inserted into a constant temperature chamber, normally maintained at 40 °C, for a minimum of 30 minutes. After the sensor has equilibrated with the temperature in the chamber for at least 30 minutes, the resistance is measured using the specialized fixture which is connected to a calibrated DC power analyzer.

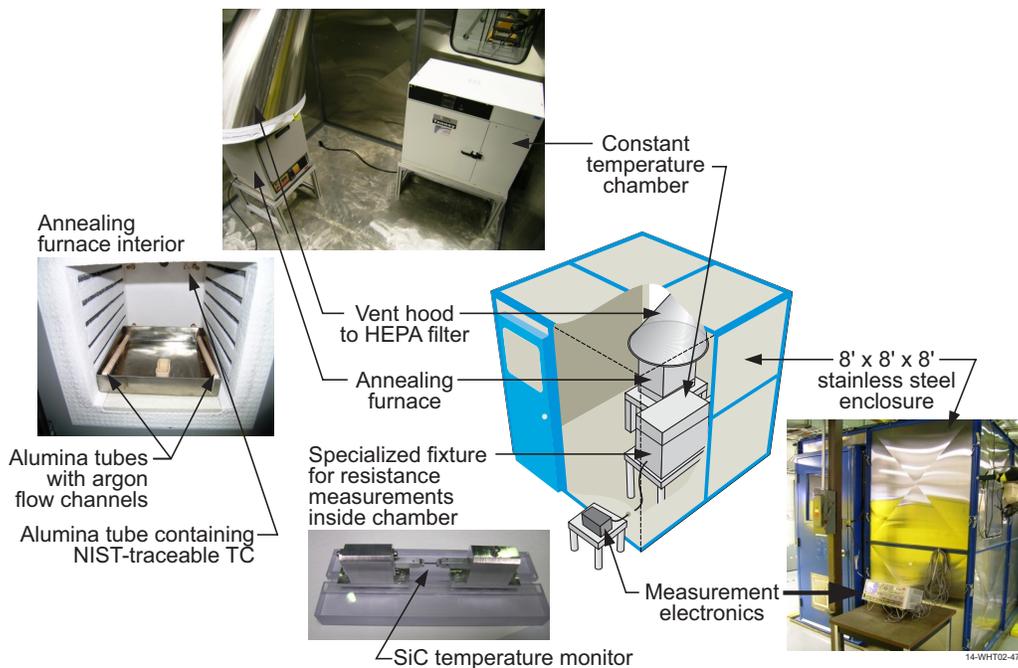


Figure 5. SiC equipment setup.

Initial resistance measurements of the SiC monitors are performed to determine the power analyzer settings to use for each post-anneal measurement. The ohmic response is used to ensure resistance heating in the sample is minimized and the current signal is stable for the given voltage. Figures 6 and 7 contain plots of the ohmic response for the KGT-1368 monitor and the KGT-1370 monitor, respectively. Based on those plots, an applied voltage of 4 V was selected for KGT-1368 to minimize resistance heating and 45 V was selected for KGT-1370 to yield a working current within the operating band of the DC analyzer.

3.3. Results

In comparing information in Table 3 and in Section 3.1, it may be observed that irradiation temperatures for one of the SiC monitors and dose ranges for all of the monitors included in the Drexel tests were not in the accepted ranges for their use (e.g., 200 to 800 °C and 1 to 8 dpa). Nevertheless, evaluations were performed to gain insights about their use in lower temperature/lower dose ranges.

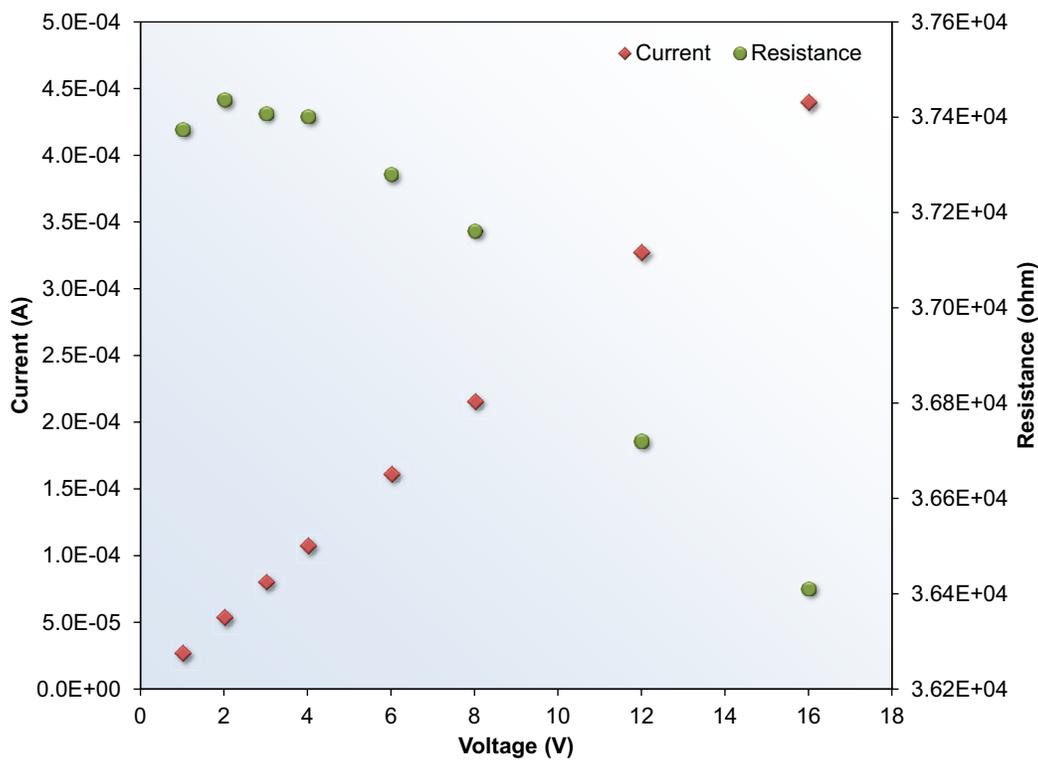


Figure 6. KGT-1368 ohmic response.

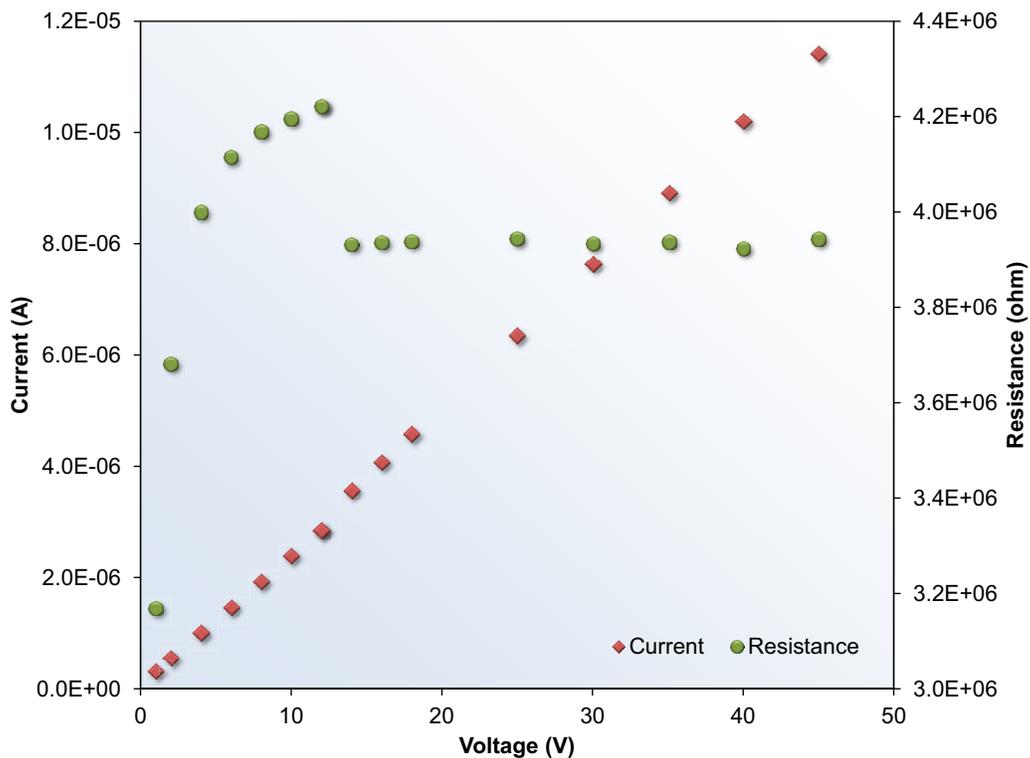


Figure 7. KGT-1370 ohmic response.

3.3.1. KGT-1368 Monitor

Figure 8 is a plot of the resistivity data for the KGT-1368 monitor. As indicated in the figure, resistivity data show more or less random scattering with no clear upward as annealing temperatures were increased. Therefore, a peak irradiation temperature based on the resistivity data was indeterminate. This result may be expected given that the predicted irradiation temperature (of 110 °C) and the planned dose for this monitor (of 0.1 dpa) were below recommended ranges of 200 to 800 °C and 1 to 8 dpa, respectively. Because there were no signs of a clear upward trend in resistivity, this evaluation was truncated at a final annealing temperature of 200 °C.

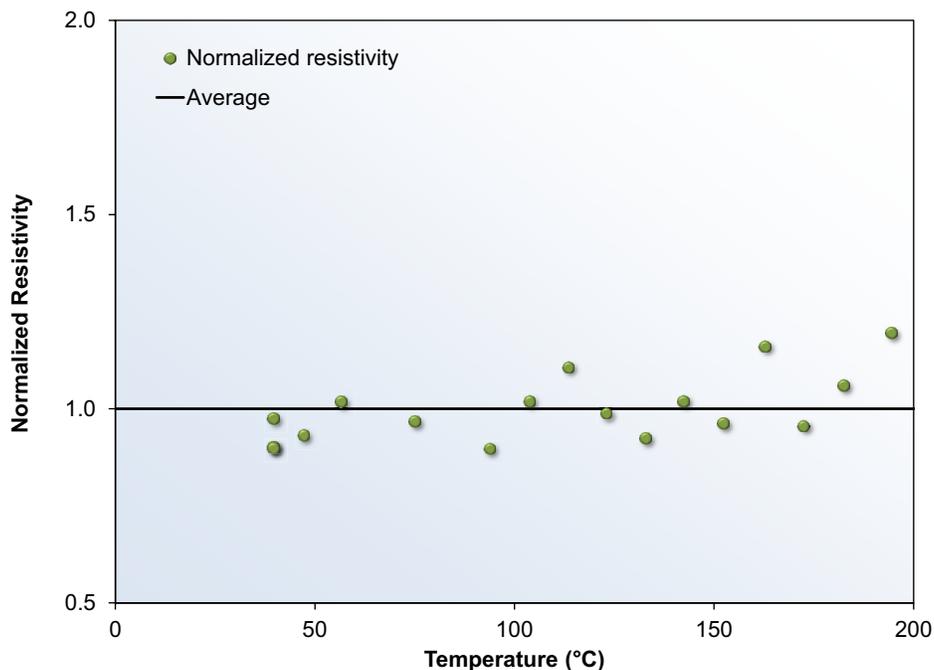


Figure 8. Resistivity data for KGT-1368 monitor.

3.3.2. KGT-1370 Monitor

Figure 9 is a plot of the resistivity data for the KGT-1370 monitor. As indicated in the figure, resistivity data show more or less random scattering with no clear upward as annealing temperatures were increased (similar to the results for the KGT-1368 monitor). Therefore, a peak irradiation temperature based on the resistivity data was indeterminate. This result may be expected given that the planned dose for this monitor (of 0.1 dpa) was below the recommended range of 1 to 8 dpa. Because there were no signs of a clear upward trend in resistivity, this evaluation was truncated at a final annealing temperature of 750 °C.

3.3.3. SiC Monitor Evaluations Summary

SiC monitors, identified as KGT-1368 and KGT-1370, were evaluated to infer peak irradiation temperatures during the ATR NSUF Drexel University Project 31091 irradiation. Peak irradiation temperatures inferred from evaluation of KGT-1368 and KGT-1370 were indeterminate, as summarized in Table 4. A primary factor contributing to the poor response of these SiC is believed to be the fact that the SiC monitors were used outside the recommended temperature and dose ranges.

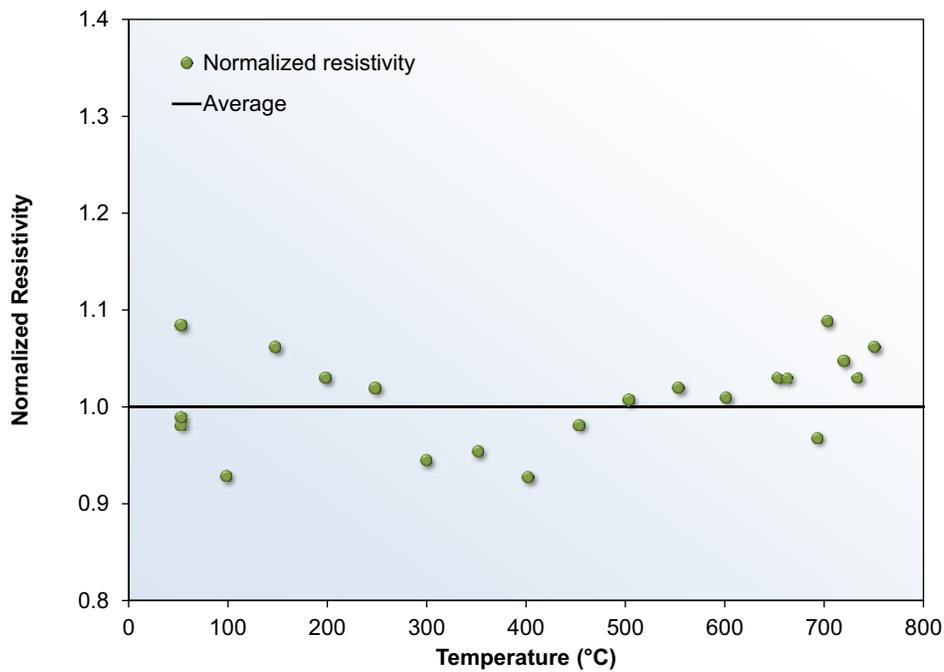


Figure 9. Resistivity data for KGT-1370 monitor.

Table 4. Summary of SiC evaluation results.

Monitor	Inferred Peak Temperature (°C)	Dose (dpa)	Predicted Test Temperature (°C)
KGT-1368	Indeterminate	0.1	110
KGT-1370	Indeterminate	0.1	725

4. Conclusions

SiC monitors were used in selected positions during the ATR NSUF Drexel University Project 31091 irradiation as a way to determine peak irradiation temperatures reached during the test. Two of the SiC monitors that were used (KGT-1368 and KGT-1370) were evaluated to infer those temperatures. However, peak irradiation temperatures inferred from evaluation of the SiC monitors were indeterminate. A primary factor contributing to the poor performance of these SiC monitors is believed to be the fact that the SiC monitors were used outside the recommended temperature and dose ranges. Based on these results, it therefore appears that SiC monitors cannot be reliably used outside of recommended temperature and dose ranges.

5. References

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